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# Determination of the positrons annihilation characteristics of the UO<sub>2</sub> lattice

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### ABSTRACT

Annealing of sintered polished UO<sub>2</sub> disks at high temperature (1700°C) has been performed in order to eliminate the defects created both during the sintering and the polishing of the disks. Several sets of such UO<sub>2</sub> disks coming from different origins have been studied in the bulk using positron lifetime spectroscopy, and near the surface using a slow positron beam coupled with Doppler broadening spectrometry. They appear homogeneous and similar using positron annihilation spectroscopy. Results show the presence of negative ions, that may be negatively charged oxygen atom located in interstitial site. The positrons annihilation characteristics of the UO<sub>2</sub> lattice have been determined and are equal to  $S_L(UO_2) = 0.371$ ,  $W_L(UO_2)=0.078$ ,  $\tau_L(UO_2)=169$ ps.

PACS codes:

78.70.Bj Positron annihilation61.72.Ji Point defects (vacancies, interstitials, color centers, etc.) and defect clusters61.82.Fk Semiconductors

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### I. INTRODUCTION

The behavior of uranium dioxide under irradiation as nuclear fuel in fission reactors has been extensively studied by using different irradiation conditions and characterization techniques.<sup>1</sup> Experimental studies are still necessary to determine the fundamental properties of defects that can be induced by irradiation such as their nature, formation energy, migration recombination energy, and so on... We propose to investigate vacancy defects in this material using positron annihilation spectroscopy.

Few results have been published concerning the study of uranium dioxide (UO<sub>2</sub>) using positron annihilation spectroscopy. Upadhyaya *et al* have examined the variation of positron lifetime with particle size in UO<sub>2</sub> powders.<sup>2</sup> Both lifetime and Doppler broadening studies of UO<sub>2</sub> are included in a study of the oxidation and hydriding of uranium by Howell *et al.*<sup>3</sup> The influence of the uranium concentration at room temperature was studied by T. Troev *et al* using Doppler broadening and positron lifetimes' measurements.<sup>4</sup> H.E. Evans *et al* have studied defect and inert gas behavior (krypton) in uranium dioxide pellets using a slow positron beam.<sup>5</sup> In previous studies we have investigated vacancy defects induced by either polishing or helium implantation in sintered polished UO<sub>2</sub> disks and their thermal evolution.<sup>6,7</sup>

But the annihilation characteristics, like the diffusion coefficient and the lattice and defects lifetimes, are not known in this material and have never been determined to our knowledge. In this work we have used both slow positron beam coupled with a Doppler broadening spectrometer and positron lifetime measurements using fast positrons to determine the positron annihilation lattice characteristics of UO<sub>2</sub>. Annealing at 1700°C has been done in order to reduce the number of defects created in the UO<sub>2</sub> disks during their fabrication.

#### **II. EXPERIMENTAL DETAILS**

Several sintered disks of uranium dioxide (0.2 at.%  $^{235}$ U) have been produced by various labs (set G from the SICN company, France and sets B and L from the CEA Cadarache, France). The sintering conditions and the powder used could thus be different. All the disks have been polished and annealed during 24 hours at 1700°C under a wet ArH<sub>2</sub> atmosphere in order to preserve their stoichiometry. The mean ratio O/U measured by polarography is equal to 2.0051±0.0001 for the disks of the set G, and the mean density is 10.76±0.03 g.cm<sup>-3</sup>. X-ray absorption spectroscopy measurements on a G set disk have shown that the surface of the disk is a thin layer of U<sub>4</sub>O<sub>9</sub> (a few nm).<sup>8</sup> The disk called Ga16 (from set G) has been chosen as a reference. Both the slow positron beam coupled with a Doppler broadening spectrometer and positron lifetime measurements were used for this study.

The positron-electron momentum distributions were measured at 300 K by recording the Doppler broadening of the 511 keV annihilation radiations. The low S and high W momentum annihilation fraction were recorded in the momentum range  $(0-|2.80|)\times10^{-3}m_0c$ and  $(|10.61|-|26.35|)\times10^{-3}m_0c$  respectively, as a function of the positron energy between 0.5 and 25.0 keV by 0.5 keV steps using a slow positron beam at the CERI-CNRS lab.<sup>9</sup> The positron mean implantation depth in UO<sub>2</sub> varies from ~1 to ~570 nm in this energy range, as calculated for Ge,<sup>10</sup> as the mean atomic number of UO<sub>2</sub> ( $Z_{UO2}$ =36) is close to the one of Ge ( $Z_{Ge}$ =32).

Positron lifetime measurements were performed using a conventional fast-fast coincidence spectrometer with a time resolution of 230 ps. A <sup>22</sup>Na positron source was sandwiched between two identical samples, and the time interval between the two photons coming from the  $\beta^+$  decay and the positron annihilation was measured as the positron lifetime as a function of the temperature in the 15-600 K range. Approximately two million events were collected for each spectrum. The lifetime spectra, equal to  $R \otimes \Sigma I_i \exp(-t/\tau_i)$ , were analyzed using a modified version of the software PosFiT,<sup>11</sup> as sums of exponential lifetime components  $\tau_i$  weighted by the intensities  $I_i$ , convoluted with a Gaussian resolution function R. The average lifetime is the center of mass of the lifetime spectrum and can be calculated as  $\tau_{av} = \Sigma I_i \tau_i$ .

#### **III. RESULTS**

The low (S) and high (W) momentum annihilation fractions were measured in the first micrometer from the surface of the disks as a function of the positron energy E. Results obtained on nineteen  $1700^{\circ}C/24h/ArH_2$  annealed UO<sub>2</sub> disks coming from the same set (G) show similar behavior of S(E) and W(E) values. Only the results obtained on the disks named Ga16 and Ga17 are represented in the Fig. 1. S decreases and W increases rapidly as a function of the positron energy from 0.5 to 2.0 keV, and then more slowly up to 5.0 keV. They remain constant between 5.0 and 25.0 keV and the S and W values of the Ga16 reference on the plateau are (S<sub>ref</sub>, W<sub>ref</sub>)=(0.3713, 0.0786). A modified version of VEPFIT,<sup>12</sup> is used to fit the S(E) and W(E) curves between 2.5 and 25.0 keV using one homogeneous layer model. A positron effective diffusion length L<sub>eff</sub><sup>+</sup> of around 9 nm is obtained. It indicates that the UO<sub>2</sub> disks can be considered as homogeneous as a function of the depth, and the S and W values found on the plateau are the annihilation characteristics of the bulk of the disks.

Measurements of the S and W values of the other sets (B and L) give also the same results as the set G (Fig. 2). The W values as a function of the energy are not represented in the figure as they have the same opposite behavior as the S one. No change is observed for the annihilation characteristics of the bulk of the disks whatever is the set, and  $L_{eff}^+$  values obtained for each set are given in Table I.

All these measures were done at 300K. Some measurements were also performed at lower temperatures in order to observe if the temperature can modify the detected defects distribution. No change has been observed whatever is the measurement temperature. Results are presented in the Fig. 3 only for the temperatures 35K, 75K and 300K. S decreases rapidly as a function of the positron energy from 0.5 to 3.0 keV, and then more slowly up to 5.0 keV. It remains constant between 5.0 and 25.0 keV. Only a difference can be observed at 0.5 keV: S and W values change as a function of the temperature. The low (S) and high (W) momentum annihilation fractions have been measured as a function of the time at low temperature, and we have observed an increase (decrease) of S (W). The variation of S and W at low positrons energy is thus due to the adsorption of a contaminated layer at the surface of the sample, which is cold. This layer is desorbed when the sample is annealed up to the room temperature. A modified version of VEPFIT has also been used to fit the S(E) and W(E) curves between 1.5 and 25.0 keV using one homogeneous layer model. The annihilation characteristics of the volume of the disks do not vary as a function of the temperature, as well as the positron effective diffusion length  $L_{eff}^+$  that is equal to 7 nm.

Positron lifetime measurements have been done on two samples of the G set annealed at 1700°C during 24 hours under a wet ArH<sub>2</sub> atmosphere. A measure performed at 300K give an average lifetime  $\tau_{av}$  equal to 168.7±1.1 ps, and a lifetime component  $\tau_1$  of 168.7±1.1 ps with an intensity I<sub>1</sub> of 100%. The positron lifetime has also been measured as a function of the temperature, between 15 K and 575 K by 25 K steps (Fig. 4). The average lifetime  $\tau_{av}$  increases first slowly between 15 and 335 K from 165 ps to 169 ps, and then more quickly between 335 and 575 K from 169 to 187 ps. For measurement temperatures under 335 K, only one lifetime component is obtained from the recorded lifetime spectra that increases from 165 to 169 ps between 15 and 335 K. Above 335 K two components have been extracted. The lifetime  $\tau_1$  of the shortest component is equal to 475 ps at 335 K and tends toward 270±40

ps with the increasing temperature. Its intensity  $I_2$  stays low until 400 K and varies from 2 to 10% after 400 K.

The lifetime spectra recorded above 335K have also been decomposed using a fixed value of  $\tau_2$  equal to 270 ps. The lifetime  $\tau_1$  of the shortest component is thus equal to 169±4ps and stays constant until 450K, then increases with the temperature up to 178ps at 575K. The I<sub>2</sub> intensity is equal to 1% at 335K and increases with the temperature up to 10% at 575K. These results show that a decomposition performed with two components is not sufficient. Decomposition of the lifetime spectra using three components have been performed, in particular with a lifetime  $\tau_2$  of the longest component equal to 307ps, which is the lifetime characteristic of a vacancy defect linked to the lack of an uranium atom in the UO<sub>2</sub> lattice.<sup>13</sup> The results are not acceptable.

Above 335K the value of  $\tau_{mod}$  (calculated as  $1/\tau_{mod} = I_1/\tau_1 + I_2/\tau_2$  and obtained for a positron trapping model in only one vacancy) is higher than the lifetime measured at low temperature. This confirms that the positrons detect more than a trap in the virgin UO<sub>2</sub> disks polished and annealed at 1700°C during 24 hours under a wet ArH<sub>2</sub> atmosphere.

Several conclusions are extracted from these results. First of all only one annihilation state is detected at low temperature (<335 K) with a lifetime of 169±4ps. Secondly the fact that a long component with a lifetime  $\tau_2$  can be extracted above 335K indicates that the positrons detect one or several vacancy traps (named V<sub>HT</sub>, as vacancy detected at high temperature). The lifetime of these defects is not easy to obtain from the spectra, because the intensity I<sub>2</sub> is low, and it is maybe several vacancy defects with a low trapping rate. These vacancy traps with a lifetime higher or equal at 270 ps are not detected at low temperature. This indicates that: (i) either these traps are created when the temperature increases and becomes higher than 335K: the trapping in these defects begins to be in competition with the annihilation in the state detected at low temperature which has a lifetime of 169±4ps ; (ii) or another trap very active at low temperature (T<sub>LT</sub>) exists, and prevent the V<sub>HT</sub> defects detection. The trapping rate at these T<sub>LT</sub> traps decreases with the increasing temperature. This kind of variation is well known for the negatively charged defects trapping coefficient.<sup>14</sup> The  $T_{LT}$  traps characteristic lifetime is 169±4ps. Moreover we have observed that the lifetime of the shortest component does not decrease when the positrons detect the V<sub>HT</sub> defects. It means thus that a trapping model with two states (the lattice and one V<sub>HT</sub> vacancy defect for example) is not available. This indicates that the annihilation state detected at low temperature cannot be the delocalized state of the lattice alone. From these lifetimes measures as a

function of the temperature one can conclude that at least two types of traps are detected by the positrons: one which has a lifetime equal to  $169\pm4ps$  prevails at low temperature (<335K), and the other(s) is/are vacancy type, and is/are detected only above 335K.

#### IV. DISCUSSION

The spatial distribution of defects seen by the positrons is homogeneous in the first micrometer from the surface as a function of the depth in the  $1700^{\circ}C/24h/ArH_2$  annealed UO<sub>2</sub> disks studied. The S and W positron annihilation characteristics in the volume of these disks do not vary whatever is the sample, the set or even the measurement temperature between 35 and 300K (Fig. 1, 2 and 3). In particular the positron effective diffusion length L<sub>eff</sub><sup>+</sup> stays around 10 nm, which is a very low value compared to the value of the diffusion length obtained in other materials without defects (100-300 nm).<sup>15</sup> This suggests either the presence of an electrical field that can drive the positrons towards the bulk of the disk, or the trapping of the positrons at a defect, preventing them to diffuse back to the surface after their thermalization.

The variation of the average lifetime as a function of the temperature shows that the positron is trapped in a negatively charged defect with a lifetime of 169 ps, which is the most detected up to 335K. The nature of these traps could be either vacancy defects or negative ions defects.

It is important to note that these UO<sub>2</sub> disks polished and annealed at 1700°C/24h/ArH<sub>2</sub> are overoxidised. Indeed a thin layer of U<sub>4</sub>O<sub>9</sub> around 9 nm has been observed on these disks by X-ray absorption spectroscopy.<sup>8</sup> Moreover the mean ratio O/U measured by polarography is equal to 2.0051±0.0001. This technique is based on the dissolution of the sample: an overconcentration of the surface cannot thus be observed. The O/U ratio higher than 2 could be due to an overconcentration of the volume, and/or to the presence of an overoxidised layer. The overconcentration in oxygen induced by the presence of the 9 nm thick U<sub>4</sub>O<sub>9</sub> layer over all the surface of these disks is approximately equal to  $10^{18}$  cm<sup>-3</sup>. This value is negligible compared to the overconcentration revealed by the polarography measures, which is around  $3.7 \times 10^{20}$  cm<sup>-3</sup>. These calculations prove that there is an oxygen excess in all the volume of the UO<sub>2</sub> disks of the set G, polished and annealed at 1700°C during 24 hours under a wet ArH<sub>2</sub> atmosphere. This over-stoichiometry indicates that these disks are p-type semiconductors.<sup>16</sup> It suggests that the negatively charged defect detected by the positron is linked to the oxygen interstitial. If it is true, one can supposed that this defect is ionic. The trapping rate can be

estimated at 300K using the Eq. (1) where  $L_{eff}^+$  is the effective diffusion length obtained from the S(E) and W(E) data adjustments (Table I) and equal to 10.8 nm in the G set disks :

$$L_{eff}^{+} = (D^{+}/(K_{IN} + \lambda_{L}))^{1/2}$$
(1)

where D<sup>+</sup> is the positrons diffusion coefficient in UO<sub>2</sub>, K<sub>IN</sub> is the trapping rate around these negative ions, and  $\lambda_L$  is the positrons annihilation rate in the delocalized state of the UO<sub>2</sub> lattice.  $D^+$  and  $\lambda_L$  are not known in UO<sub>2</sub>. If the traps active at low temperature are negative ions, their lifetime is close to the characteristic lifetime in the UO<sub>2</sub> lattice, and so  $\lambda_L$  is equal to  $1/169 \text{ s}^{-1}$ . It is also supposed that D<sup>+</sup> is equal to 1.5 cm<sup>2</sup>.s<sup>-1</sup>, the mean value obtained at 300K in several metals.<sup>17</sup> Thus the trapping rate is equal to  $10^{12}$  s<sup>-1</sup> at 300K in the polished and annealed 1700°C/24h/ArH<sub>2</sub> UO<sub>2</sub> disks. If the interstitial oxygen type negative traps specific trapping coefficient is equal to the value determined at 300K for the negatively charged antisite  $Ga_{As}$  in GaAs which is  $3x10^{15}$  at.s<sup>-1</sup>,<sup>15</sup> the traps concentration in the UO<sub>2</sub> disks from the set G is equal to  $3 \times 10^{19}$  cm<sup>-3</sup>. If one supposes that an acceptor trap is linked to only one oxygen interstitial atom, the off-stoichiometry is around  $4 \times 10^{-4}$ . This value is 10 times lower than the one determined by polarography  $(5 \times 10^{-3})$ . An off-stoichiometry equivalent to the one measured by polarography can be obtained for a specific trapping rate of  $2.5 \times 10^{14}$  at s<sup>-1</sup>. Moreover some of the oxygen interstitials can help in the Willis clusters formation,<sup>18</sup> that are typical defects of the over-oxidation of UO<sub>2</sub> which contain two oxygen interstitials in a defect. This confirms that the active traps at low temperature are negative ions linked to the oxygen interstitial.

Above 335K a second lifetime component appears and shows clearly the presence of vacancy defects. The trapping rate in these defects is negligible at low temperatures and stays low at higher temperature. This can be explained either because these vacancy defects are neutral and their trapping rate and concentration are lower than those of the negative ions, or because these defects appear only above 335K. Above 300K Willis clusters composed of an oxygen divacancy and four oxygen interstitials could be formed. X-ray Photoelectron Spectroscopy (XPS) measures have been performed on an annealed  $1300^{\circ}C/24h/ArH_2 UO_2$  disk, and then annealed at 670K under vacuum using the setup where are done the lifetime measurements as a function of temperature. No overoxidation of the surface has been observed; this thus suggests that no Willis clusters have been introduced during our lifetime measurements performed in the same conditions (up to 575K). Moreover the vacancy defects formation energy in UO<sub>2</sub> seems to be high according to the theory and the experimental results.<sup>19</sup> It is thus unlikely that vacancy defects could be created at 335K.

The positrons measurements performed on the different UO<sub>2</sub> disks coming from different sets show that the annealing at high temperature (1700°C) during 24 hours under a wet ArH<sub>2</sub> atmosphere eliminates the detection of the defects created by both the sintering and the polishing of the disks. It also shows the presence of negative ions. The Rydberg states around the negative ions are not very deep traps for the positrons, in which they do not see free volume. Moreover the trapped positrons in the Rydberg state are far away from the ion centre (Rydberg radius 1-10 nm,<sup>15</sup>) and probe only the interstices. Thus the Rydberg states annihilation characteristics are similar to those of the lattice.<sup>15</sup> Consequently the annihilation characteristics found in these polished and annealed 1700°C/24h/ArH<sub>2</sub> UO<sub>2</sub> disks, for temperatures lower or equal to 300K, could be those of the UO<sub>2</sub> lattice: S<sub>L</sub>(UO<sub>2</sub>) = 0.371, W<sub>L</sub>(UO<sub>2</sub>)=0.078,  $\tau_L$ (UO<sub>2</sub>)=169ps.

Positrons lifetime in the UO<sub>2</sub> lattice can be estimated using the linear dependence found for various semiconductors between the unit cell volume and the positron bulk lifetime:<sup>20</sup>  $\tau_L = C_1 \ge a_0^{3/2}$ , where  $a_0$  is the unit cell volume in nm<sup>1.5</sup> and  $C_1$  a constant equal to 543.8 ps.nm<sup>-1.5</sup>. Using the unit cell volume in UO<sub>2</sub> that is equal to 5.47 $\times$ 10<sup>-1</sup> nm, the positron lattice lifetime is found to be 220 ps. This value is higher than the one obtained in this work. One should note that this equation gives lattice lifetimes values 20 ps higher for SiC and GaN. The difference is 50 ps in UO<sub>2</sub>. This could be also explained by the high ionicity of UO<sub>2</sub>, equal to 0.93,<sup>21</sup> compared to those of Si or Ge, equal to 0.

#### V. CONCLUSION

Measures of Doppler broadening of the 511 keV annihilation radiation performed with slow positrons show that the polished and annealed  $1700^{\circ}C/24h/ArH_2$  UO<sub>2</sub> disks are homogeneous and similar whatever is the set and the sample. The low positron effective diffusion length  $L_{eff}^+$  obtained and the variation of the lifetime as a function of the temperature can be explained by the presence of negative ions. We propose that these negative ions are negatively charged oxygen atom located in interstitial site. The positrons annihilation characteristics of the UO<sub>2</sub> lattice have been determined:  $S_L(UO_2) = 0.371$ ,  $W_L(UO_2)=0.078$ ,  $\tau_L(UO_2)=169$ ps.

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## TABLE CAPTION

TABLE I: Positron effective diffusion length  $L_{eff}^+$  in the G, B and L sets of UO<sub>2</sub> disks as determined by adjusting S(E) and W(E) experimental data with a modified VEPFIT program, <sup>12</sup> using a model with one homogeneous layer.

## FIGURE CAPTIONS

**FIG. 1:** Relative low momentum fraction  $S/S_{ref}$  (a) and relative high momentum fraction  $W/W_{ref}$  (b) as a function of positron energy, and  $S/S_{ref}$  as a function of  $W/W_{ref}$  (c) in the Ga16 (*squares*) and Ga17 (*triangles*) UO<sub>2</sub> disks polished and annealed during 24 hours at 1700°C under a wet ArH<sub>2</sub> atmosphere. The solids lines are a fit of the (S, W) curves with a model of homogeneous layers using a modified version of VEPFIT.<sup>12</sup>

**FIG. 2:** Relative low momentum fraction  $S/S_{ref}$  as a function of positron energy (a), and  $S/S_{ref}$  as a function of  $W/W_{ref}$  (b) in the G (*squares*), L (*triangles*) and B (*stars*) UO<sub>2</sub> disks polished and annealed during 24 hours at 1700°C under a wet ArH<sub>2</sub> atmosphere.

**FIG. 3:** Relative low momentum fraction  $S/S_{ref}$  as a function of positron energy (a), and  $S/S_{ref}$  as a function of  $W/W_{ref}$  (b) in the Ga48 UO<sub>2</sub> disk polished and annealed during 24 hours at 1700°C under a wet ArH<sub>2</sub> atmosphere, obtained for different measurement temperatures 35K (*stars*), 70K (*triangles*) and 300 K (*squares*).

**FIG. 4:** Temperature dependence of the positron lifetime spectra decomposition in  $1700^{\circ}C/24h/ArH_2$  annealed UO<sub>2</sub> disks of the set G: (a) average lifetime  $\tau_{av}$ ; (b) lifetime  $\tau_1$  of the shortest component; (c) lifetime  $\tau_2$  of the longest component; (d) its intensity I<sub>2</sub>. Lines are guide to the eyes.

	Set G	Set B	Set L
$L_{eff}^{+}(nm)$	10.80	8.21	9.35

Table I



FIGURE 1



FIGURE 2



FIGURE 3



FIGURE 4